Jc662 U.S. PTO
09/685414
10/10/00

430 288.1
Class | Subclass
ISSUE CLASSIFICATION

PATENT NUMBER

U.S. UTILITY PATENT APPLICATION

O.I.P.E.
SCANNED _____ Q.A. _____

PATENT DATE

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
09/685414	D	430	288.1	1752	C. Hamilton

APPLICANTS

Ali Afzali-Ardakani
Tricia Breen
Jeffrey Gelorme
David Mitzi

ABANDONED

TITLE

High sensitivity crosslinkable photoresist composition, based on soluble, film forming dendrimeric calix[4]arene compositions method and for use thereof

PTO-2040
12/99

PREPARED AND APPROVED FOR ISSUE

ISSUING CLASSIFICATION

ORIGINAL			CROSS REFERENCE(S)						
CLASS	**SUBCLASS**	**CLASS**	**SUBCLASS (ONE SUBCLASS PER BLOCK)**						
430	288.1	430	270.1	318	323				

INTERNATIONAL CLASSIFICATION	
G03F	7/40
G03F	7/038

☐ Continued on Issue Slip Inside File Jacket

TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
☐	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
	2	2	None	13	1, 7

☐ a) The term of this patent subsequent to _____ (date) has been disclaimed.

None
(Assistant Examiner)   (Date)

☐ b) The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____

Cynthia Hamilton
CYNTHIA HAMILTON
PRIMARY EXAMINER
Hamilton
5-10-02
(Primary Examiner)   (Date)

☐ c) The terminal _____ months of this patent have been disclaimed.

_____
(Legal Instruments Examiner)   (Date)

NOTICE OF ALLOWANCE MAILED

5-15-02

ISSUE FEE

Amount Due	Date Paid
$1280.00	

ISSUE BATCH NUMBER

WARNING:

The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368. Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.

Form PTO-436A
(Rev. 6/98)

(LABEL AREA)

(FACE)